

APPROVED: /EA/

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FEB 07 2011****IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re PATENT Application of:

Hindrik Willem De Vries

Appl. S.N.: 10/584,075

Filing  
Date: 07-16-2008Title: Method of and Arrangement for Removing  
Contaminants from a Substrate Surface Using  
an Atmospheric Pressure Glow Plasma

Confirmation No.: 8763

Attorney Docket: 2602-0011

Group Art Unit: 2821

Examiner: ALEMU, EPHREM

Date: February 7, 2011

**AMENDMENT**

Hon. Commissioner of Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated 11/02/2010, please amend the application as follows:

A listing of the claims including amended claims begins on page 2 of this paper.

Remarks begin on page 7 of this paper.

A modified Terminal Disclaimer is attached hereto at the end of the Response.